

L Number	Hits	Search Text	DB	Time stamp
2	9	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (oxidiz\$4)	USPAT	2004/05/27 11:50
3	2	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (oxidiz\$4) same reduc\$4	USPAT	2004/05/27 10:34
1	12	("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.	USPAT	2004/05/27 10:40
4	3966	ruthenium near2 oxide	USPAT	2004/05/27 10:40
5	29	ruthenium near2 oxide near10 stack\$4	USPAT	2004/05/27 10:43
7	27	ruthenium near2 oxide near10 alternat\$4	USPAT	2004/05/27 10:44
6	3	ruthenium near2 oxide near10 alternating	USPAT	2004/05/27 10:46
8	743	(sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)	USPAT	2004/05/27 10:47
9	231	((sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)) and (reducing or hydrogen or "h.sub.2") near3 (gas\$4 or reactant or precursor)	USPAT	2004/05/27 10:47
10	113	((sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)) and (reducing or hydrogen or "h.sub.2") near3 (gas\$4 or reactant or precursor) and (oxidiz\$4 or oxygen or "o.sub.2") near3 (reactant or precursor or gas\$4)	USPAT	2004/05/27 10:48
11	61	((sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)) and (reducing or hydrogen or "h.sub.2") near3 (gas\$4 or reactant or precursor) same deposit\$5 and (oxidiz\$4 or oxygen or "o.sub.2") near3 (reactant or precursor or gas\$4)	USPAT	2004/05/27 10:48
12	47	((sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)) and (reducing or hydrogen or "h.sub.2") near3 (gas\$4 or reactant or precursor) same deposit\$5 and (oxidiz\$4 or oxygen or "o.sub.2") near3 (reactant or precursor or gas\$4) same deposit\$5	USPAT	2004/05/27 10:50
13	13	((sequential or puls\$4) near5 (cvd or mocvd or movpe or omvpe or vapor near2 deposit\$4 or vapor near2 epitax\$4)) and (reducing or hydrogen or "h.sub.2") near3 (gas\$4 or reactant or precursor) same deposit\$5 and (oxidiz\$4 or oxygen or "o.sub.2") near3 (reactant or precursor or gas\$4) same deposit\$5 and metal near2 organ\$5	USPAT	2004/05/27 11:03
14	3	("6201271" "6180974" "6140230").pn.	USPAT	2004/05/27 11:11
15	9589	mocvd or movpe or omvpe or omcvd or metal\$4 near2 organ\$5 near5 (deposit\$5 or epitax\$5 or grow\$4)	USPAT	2004/05/27 11:12

16	71	(mocvd or movpe or omvpe or omcvd or metal\$4 near2 organ\$5 near5 (deposit\$5 or epitax\$5 or grow\$4)) and alternat\$4 same (reduc\$4 and oxidiz\$4)	USPAT	2004/05/27 11:13
17	15	(mocvd or movpe or omvpe or omcvd or metal\$4 near2 organ\$5 near5 (deposit\$5 or epitax\$5 or grow\$4)) and alternating same (reduc\$4 and oxidiz\$4)	USPAT	2004/05/27 11:50
18	0	20030119313.pn.	USPAT	2004/05/27 11:50
19	0	"20030119313"	USPAT	2004/05/27 11:50
20	0	"200300119313"	USPAT	2004/05/27 11:50
21	0	"2003119313"	USPAT	2004/05/27 11:50
22	9	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (oxidiz\$4)	USPAT	2004/05/27 11:50
23	0	"200300119313"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/27 11:51
24	2	"20030119313"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/27 11:51
-	2	20030100183.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:26
-	12773	mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:27
-	14486	(mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:28
-	84	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:30
-	35	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o")) and reactant near10 ("n.sub.2o" or "o.sub.2" or "no" or "o.sub.3" or oxygen or ozone or nitrous near2 oxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:31
-	214	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o" or water or ammonia or hydrogen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:31
-	79	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o" or water or ammonia or hydrogen)) and reactant near10 ("n.sub.2o" or "o.sub.2" or "no" or "o.sub.3" or oxygen or ozone or nitrous near2 oxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:36

-	111	(weimin near2 li or mark near2 visokay).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:32
-	22	((weimin near2 li or mark near2 visokay).in.) and mocvd	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:32
-	5	((((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o" or water or ammonia or hydrogen)) and reactant near10 ("n.sub.2o" or "o.sub.2" or "no" or "o.sub.3" or oxygen or ozone or nitrous near2 oxide)) and ((weimin near2 li or mark near2 visokay).in.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:33
-	26	((((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and reactant near10 ("nh.sub.3" or "h.sub.2" or "h.sub.2o" or water or ammonia or hydrogen)) and reactant near10 ("n.sub.2o" or "o.sub.2" or "no" or "o.sub.3" or oxygen or ozone or nitrous near2 oxide)) and sequential	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:43
-	183	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and alternat\$5 same (reduc\$5 and oxidiz\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:43
-	22	((mocvd or metal near2 organic near2 (deposit\$5 or epitax\$4)) or movpe) and alternat\$5 near10 (reduc\$5 and oxidiz\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/25 16:43
-	12	("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.	USPAT	2004/05/27 10:33
-	12	("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.	USPAT	2004/05/26 10:19
-	10	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (mocvd or movpe or metal near2 organic)	USPAT	2004/05/26 10:19
-	7	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (mocvd or movpe or metal near2 organic)) and oxidiz\$4	USPAT	2004/05/26 10:20
-	1	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and (mocvd or movpe or metal near2 organic)) and oxidiz\$4 same reduc\$5	USPAT	2004/05/26 10:21
-	2	((("5504041" "5576928" "5619393" "5622893" "5729054" "5807774" "5844318" "5874364" "5963835" "5989338" "6090701" "6177351").PN.) and oxidiz\$4 same reduc\$5	USPAT	2004/05/26 10:50
-	9	yang near2 haining.in. and stack\$4	USPAT	2004/05/26 10:51

-	18	yang near2 haining.in. and stack\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 10:59
-	6	5874364.pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 11:56
-	735	(yang near2 haining or gurtej near2 sandhu).in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 11:57
-	4	(yang near2 haining or gurtej near2 sandhu).in. and reducer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:12
-	2	(metal near2 organic or movpe or mocvd or omvpe) same (platinum or pt) near5 reactant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:13
-	21	methylcyclopentadienyl adj trimethyl adj platinum	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:16
-	30	"mecppte.sub.3"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:18
-	0	"ptacac.sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:19
-	0	"pt(acac).sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:34
-	7	dicarbonyl near2 cyclopentadienyl near2 rhodium	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:35
-	24	(mocvd or organic near2 vapor near2 deposition) and (rhodium or rh) near5 precursor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:37
-	1	(mocvd or organic near2 vapor near2 deposition) and dcdr	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:40
-	1099	(rhodium or rh) near10 (reactant or precursor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:40
-	30	(rhodium or rh) near10 (reactant or precursor) near10 organometallic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:44

-	13	(rhodium or rh) near10 (reactant or precursor) near10 cyclopentadienyl	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:52
-	120	(rhodium or rh) near10 cyclopentadienyl	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:55
-	4	((rhodium or rh) near10 cyclopentadienyl) and (mocvd or 117/84-109.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:55
-	0	"cprhco.sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 14:58
-	41	rh near5 cp	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 15:43
-	4	rh near10 cp same (reactant or precursor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 15:45
-	194	(rh or rhodium) near15 (cp or cyclopentadienyl)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 15:46
-	21	(rh or rhodium) near15 (cp or cyclopentadienyl) same (reactant or precursor)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:08
-	7470	(mocvd or metal near2 organic near3 (deposit\$4 or epitax\$5)) and (oxid\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:13
-	2706	(mocvd or metal near2 organic near3 (deposit\$4 or epitax\$5)) and (oxid\$5) same reduc\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:13
-	161	(mocvd or metal near2 organic near3 (deposit\$4 or epitax\$5)) and (oxid\$5) same reduc\$4 same (platinum or rhodium)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:14
-	13	(mocvd or metal near2 organic near3 (deposit\$4 or epitax\$5)) and (oxid\$5) same reduc\$4 same (platinum or rhodium) same (multi\$1layer\$4 or stack\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:24
-	6	("20030119313" "20030052356" "20020086108").pn.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/26 16:25

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